



PATENT APPLICATION

RCE/1753  
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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Date November 26, 2004

In re the Application of

Satoshi TATSUURA et al.

Group Art Unit: 1753

Application No.: 10/082,228

Examiner: E. Wong

Filed: February 26, 2002

Docket No.: 106200.01

For: METHOD FOR ELECTRODEPOSITED FILM FORMATION, METHOD FOR ELECTRODE FORMATION, AND APPARATUS FOR ELECTRODEPOSITED FILM FORMATION

**LARGE ENTITY PETITION FOR 1<sup>st</sup> - 3<sup>rd</sup> EXTENSION  
OF TIME UNDER 37 C.F.R. §1.136(a) AND  
TRANSMITTAL OF FEE UNDER 37 C.F.R. §1.17**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Transmitted herewith is a response to the outstanding Official Action in the above-identified patent application. The shortened statutory period having expired October 14, 2004, an extension of time for a period of 2 month is hereby requested. Attached hereto is our Check No. 160955 in the amount of \$430.00 in payment for:

_____	Extension fee for response within first month pursuant to §1.136(a) (\$110.00)
<u>XX</u>	Extension fee for response within second month pursuant to §1.136(a) (\$430.00)
_____	Extension fee for response within third month pursuant to §1.136(a) (\$980.00)

The Commissioner is hereby authorized to charge any additional fee or credit any overpayment associated with this communication to Deposit Account No. 15-0461. Two copies of this petition are enclosed.

11/29/2004 HDEMESS1 00000016 10082228

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430.00 DP

Respectfully submitted,

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JAO:MLM/jam

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DEPOSIT ACCOUNT USE AUTHORIZATION Please grant any extension necessary for entry; Charge any fee due to our Deposit Account No. 15-0461
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